The listing of claims will replace all prior versions, and listings, of claims

in the application:

Listing of Claims:

1 - 39. (Cancelled)

40. (Previously Presented) A process for treating a fluorine compound-

containing gas, comprising:

contacting a gas stream containing at least one compound consisting of (a)

carbon and fluorine, (b) carbon, hydrogen and fluorine, (c) carbon, hydrogen,

oxygen and fluorine, (d) SF₆, and (e) NF₃, wherein the concentration of the

fluorine compound is 0.5 to 10% by volume, with a catalyst comprising alumina

as an active compound and 7.2 to 49.4 wt.% of nickel oxide, said catalyst

containing a composite oxide of aluminum and nickel;

adding steam or a reaction gas containing steam and oxygen to the gas

stream; and

effecting a hydrolysis reaction between the at least one compound and the

steam, thereby producing a treated gas containing hydrogen fluoride,

wherein the decomposition activity of the catalyst for fluorine compounds

is maintained at a decomposition rate of about 80% or greater.

Page 2 of 11

Serial No. 09/005,006

Amendment Dated: 04/23/2004

Reply to Office Action Mailed 12/23/2003

41. (Previously Presented) A process according to Claim 40, further

comprising washing the treated gas with water to remove the hydrogen fluoride.

42. (Previously Presented) A process according to Claim 40, further

comprising washing the treated gas with an alkaline solution or slurry to

neutralize the hydrogen fluoride and other acidic compounds.

43. (Previously Presented) A process according to Claim 40, further

comprising washing the treated gas with water and subsequently neutralizing

the water that has absorbed the hydrogen fluoride with an alkaline solution or

slurry.

44. (Previously Presented) A process according to Claim 40, wherein the

catalyst further comprises zinc oxide, and wherein a ratio of aluminum to a total

of nickel and zinc is 50 to 99: 50 to 1 by atom.

45. (Previously Presented) A process according to Claim 40, wherein the

catalyst consists essentially of alumina and nickel oxide and a composite oxide of

aluminum and nickel.

Page 3 of 11

Serial No. 09/005,006

Amendment Dated: 04/23/2004

Reply to Office Action Mailed 12/23/2003

46. (Previously Presented) A process according to Claim 40, wherein the

at least one compound is at least one compound selected from the group

consisting of CF₄, C₂F₆, C₃F₈, C₄F₈, C₅F₈, CHF₃, CH₂F₂, CH₃F, C₂HF₅, C₂H₂F₄,

 $C_2H_3F_3$, $C_2H_4F_2$, C_2H_5F , CH_2OCF_2 , SF_6 , and NF_3 .

47. (Previously Presented) A process according to Claim 40, wherein the

at least one compound is at least one compound selected from the group

consisting of CF₄, C₂F₆, C₃F₈, C₄F₈, C₅F₈, CHF₃, CH₂F₂, CH₃F, C₂HF₅, C₂H₂F₄,

C₂H₃F₃, C₂H₄F₂, C₂H₅F, SF₆, and NF₃.

48. (Currently Amended) A method of treating a gas containing a

perfluoro-compound, comprising:

contacting the gas containing a fluorine compound in a concentration of

0.5 to 10% by volume at a temperature of 400 to 800°C with a catalyst

comprising aluminum oxide as an active component and 7.2 to 49.4 wt.% of

nickel oxide, said catalyst containing a composite oxide of aluminum and nickel,

in the presence of steam, whereby the perfluoro-compound is decomposed by

hydrolysis to produce a treated gas containing hydrogen fluoride and acidic

compounds; and

contacting the treated gas with water to absorb the hydrogen fluoride and

the acidic compounds from the treated gas,

Page 4 of 11

wherein the decomposition activity of the catalyst <u>for</u> relative to fluorine compounds is maintained at a decomposition rate of about 80% or greater.

- 49. (Previously Presented) A process according to Claim 48, wherein the perfluoro compound is at least one compound selected from the group consisting of CF₄, CHF₃, C₂F₆, C₃F₈, C₄F₈, SF₆ and NF₃.
- 50. (Previously Presented) A process according to Claim 48, wherein the catalyst further comprises zinc oxide, the balance being aluminum oxide.
- 51. (Previously Presented) A process according to Claim 48, wherein the catalyst consists essentially of alumina and nickel oxide and composite oxide of aluminum and nickel.

52 - 74. (Cancelled)

- 75. (Withdrawn)A process according to claim 40, wherein the compound in the gas stream is SF₆.
- 76. (Withdrawn) A process according to claim 40, wherein the compound in the gas stream is carbon, fluorine and hydrogen.

Serial No. 09/005,006

Amendment Dated: 04/23/2004

Reply to Office Action Mailed 12/23/2003

77. (Withdrawn) A process according to claim 40, wherein the

compound in the gas stream is NF₃.

78. (Withdrawn) A process according to claim 40, wherein the

compound in the gas stream is at least one member selected from the group

consisting of CHF₃, CH₂F₂, CH₃F, C₂HF₅, C₂H₂F₄, C₂H₃F₃, C₂H₄F₂, C₂H₅F,

CH₂OCF₂, SF₆ and NF₃.

79. (Previously Presented) A process according to claim 40, wherein

the fluorine compound-containing gas to be treated is used as etchants or

cleaners for semiconductors.

80. (Previously Presented) A process for treating a fluorine compound-

containing gas, comprising:

contacting a gas stream containing at least one compound consisting of (a)

carbon and fluorine, wherein the concentration of the fluorine compound is 2 to

10% by volume, with a catalyst comprising alumina as an active compound and

7.2 to 38.6 wt.% of nickel oxide, said catalyst containing a composite oxide of

aluminum and nickel;

adding steam or a reaction gas containing steam and oxygen to the gas

stream; and

Page 6 of 11

effecting a hydrolysis reaction between the at least one compound and the

steam, thereby producing a treated gas containing hydrogen fluoride, wherein a

decomposition rate of the at least one compound is maintained at about 80% or

greater.

81. (Previously Presented) A process for treating a fluorine compound-

containing gas, comprising:

contacting a gas stream containing at least one compound consisting of (a)

carbon and fluorine at a temperature from about 400 °C to about 800°C, wherein

the concentration of the fluorine compound is 0.5 to 10% by volume, with a

catalyst comprising alumina as an active compound and 7.2 to 38.6 wt.% of

nickel oxide, said catalyst containing a composite oxide of aluminum and nickel,

adding steam or a reaction gas containing steam and oxygen to the gas

stream; and

effecting a hydrolysis reaction between the at least one compound and the

steam, thereby producing a treated gas containing hydrogen fluoride, wherein a

decomposition rate of the at least one compound is maintained at about 80% or

greater.

82. (Previously Presented) The process of claim 81, wherein said gas

stream is contacted with said catalyst at a temperature from about 400 °C to

about 700°C.

Page 7 of 11

83. (Previously Presented) A process for treating a fluorine compound-

containing gas, comprising:

contacting a gas stream containing at least one compound consisting of (a)

carbon and fluorine at a temperature from about 400 °C to about 700°C, wherein

the concentration of the fluorine compound is 0.5 to 10% by volume, with a

catalyst comprising alumina as an active compound and about 20 to about 30

wt.% of nickel oxide, said catalyst containing a composite oxide of aluminum and

nickel,

adding steam or a reaction gas containing steam and oxygen to the gas

stream; and

effecting a hydrolysis reaction between the at least one compound and the

steam, thereby producing a treated gas containing hydrogen fluoride, wherein a

decomposition rate of the at least one compound is maintained at about 95% or

greater.

84. (Previously Presented) The process of claim 83, wherein said gas

stream is contacted with said catalyst at a temperature from about 400 °C to

about 700°C.

85. (New) The process of claim 40, wherein said decomposition activity of

the catalyst for fluorine compounds is maintained by the nickel oxide additive.

Page 8 of 11

Serial No. 09/005,006 Amendment Dated: 04/23/2004 Reply to Office Action Mailed 12/23/2003

86. (New) The process of claim 48, wherein said decomposition activity of the catalyst for fluorine compounds is maintained by the nickel oxide additive.